

# NX6010H GaN TRANSISTOR

Document Number: NX6010H  
Preliminary Datasheet V1.2

## Gallium Nitride 28V 100W, RF Power Transistor

### Description

The NX6010H is a 100W 28V, GaN HEMT, designed for multiple applications with frequencies up to 4GHz.

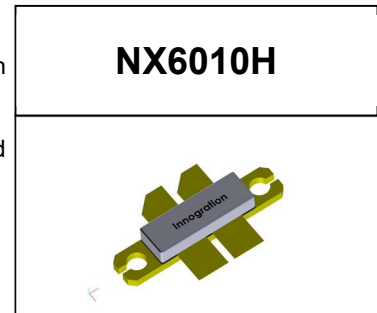
There is no guarantee of performance when this part is used in applications designed Outside of these frequencies.

It is also the dual-path version of single ended NU6006H.

- Typical performance (on Innogration narrow band fixture with device soldered)

$V_{DD}=28V$   $I_{DQ}=600mA$ , CW.

Frequency(MHz)	Gp (dB)	$P_{sat}$ (W)	Efficiency (%)
1300	19	110	70



### Applications and Features

- Suitable for wireless communication infrastructure, wideband amplifier, EMC testing, ISM etc.
- High Efficiency and Linear Gain Operations
- Thermally Enhanced Industry Standard Package
- High Reliability Metallization Process
- Excellent thermal Stability and Excellent Ruggedness
- Compliant to Restriction of Hazardous Substances (RoHS) Directive 2002/95/EC

### Important Note: Proper Biasing Sequence for GaN HEMT Transistors

#### Turning the device ON

1. Set VGS to the pinch—off (VP) voltage, typically  $-5V$
2. Turn on VDS to nominal supply voltage (28V)
3. Increase VGS until IDS current is attained
4. Apply RF input power to desired level

#### Turning the device OFF

1. Turn RF power off
2. Reduce VGS down to VP, typically  $-5V$
3. Reduce VDS down to 0 V
4. Turn off VGS

**Table 1. Maximum Ratings (Not simultaneous, TC = 25°C unless otherwise noted)**

Rating	Symbol	Value	Unit
Drain—Source Voltage	$V_{DSS}$	150	Vdc
Gate—Source Voltage	$V_{GS}$	-10,+2	Vdc
Operating Voltage	$V_{DD}$	40	Vdc
Maximum Forward Gate Current	$I_{gmax}$	28.8	mA
Storage Temperature Range	$T_{stg}$	-65 to +150	°C
Case Operating Temperature	$T_c$	+150	°C
Operating Junction Temperature(See note 1)	$T_J$	+200	°C
Total Device Power Dissipation (Derated above 25°C, see note 2)	$P_{diss}$	150	W

1. Continuous operation at maximum junction temperature will affect MTTF
2. Bias Conditions should also satisfy the following expression:  $P_{diss} < (T_J - T_c) / R_{JC}$  and  $T_c = T_{case}$

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**Table 2. Thermal Characteristics**

Characteristic	Symbol	Value	Unit
Thermal Resistance, Junction to Case $T_C = 85^\circ\text{C}$ , $T_J = 200^\circ\text{C}$ , DC Power Dissipation(See note 1)	$R_{\theta JC-DC}$	1.25	C/W

$R_{\theta JC-DC}$  is tested at only DC condition, it is related to the highest thermal resistor value among all test conditions. It might be differently lower in different RF operation conditions like CW signal ,pulsed RF signal etc.

**Table 3. Electrical Characteristics** ( $T_C = 25^\circ\text{C}$  unless otherwise noted)

**DC Characteristics**

Characteristic	Conditions	Symbol	Min	Typ	Max	Unit
Drain-Source Breakdown Voltage	$V_{GS} = -8\text{V}$ ; $I_{DS} = 28.8\text{mA}$	$V_{DSS}$	150			V
Gate Threshold Voltage	$V_{DS} = 28\text{V}$ , $I_D = 28.8\text{mA}$	$V_{GS(th)}$		-2.7		V
Gate Quiescent Voltage	$V_{DS} = 28\text{V}$ , $I_{DS} = 600\text{mA}$ , Measured in Functional Test	$V_{GS(Q)}$		-2.3		V

**Functional Tests (In Innogration narrow band Test Fixture, 50 ohm system) :**  $V_{DD} = 28\text{ Vdc}$ ,  $I_{DQ} = 600\text{ mA}$ ,  $f = 1300\text{ MHz}$ , CW

Characteristic	Symbol	Min	Typ	Max	Unit
Power Gain @ $P_{sat}$	$G_p$		19		dB
Drain Efficiency @ $P_{sat}$	$Eff$		70		%
Saturated Power	$P_{sat}$		110		W
Input Return Loss	IRL		-7		dB
Mismatch stress at all phases (Device no damage)	VSWR		10:1		$\Psi$

**Loadpull data (half section only):**

Test condition: (100us, 10% duty cycle),  $V_{ds} = 28\text{V}$ ,  $I_{dq} = 150\text{mA}$ , Gain is defined as compressed gain at  $P_{out}$

NU6006H	Freq (MHz)	VDD (V)	Idq (mA)	Zsource (ohms)	Zload (ohms)	Pout (dBm)	Gain (dB)	Eff (%)
MXP	1500	28	150	$1.0 + j*1.0$	$3.8 - j*2.3$	49.85	18.61	77.76
MXE	1500	28	150	$1.0 + j*1.0$	$5.3 + j*1.2$	48.07	20.17	86.01
Trade Off	1500	28	150	$1.0 + j*1.0$	$4.4 - j*0.6$	49.35	19.83	83.08

NU6006H	Freq (MHz)	VDD (V)	Idq (mA)	Zsource (ohms)	Zload (ohms)	Pout (dBm)	Gain (dB)	Eff (%)
MXP	2000	28	150	$0.9 - j*1.0$	$3.1 - j*3.4$	49.50	16.19	77.73
MXE	2000	28	150	$0.9 - j*1.0$	$3.4 - j*1.3$	48.39	17.65	82.80
Trade Off	2000	28	150	$0.9 - j*1.0$	$3.4 - j*2.1$	49	17.16	81.37

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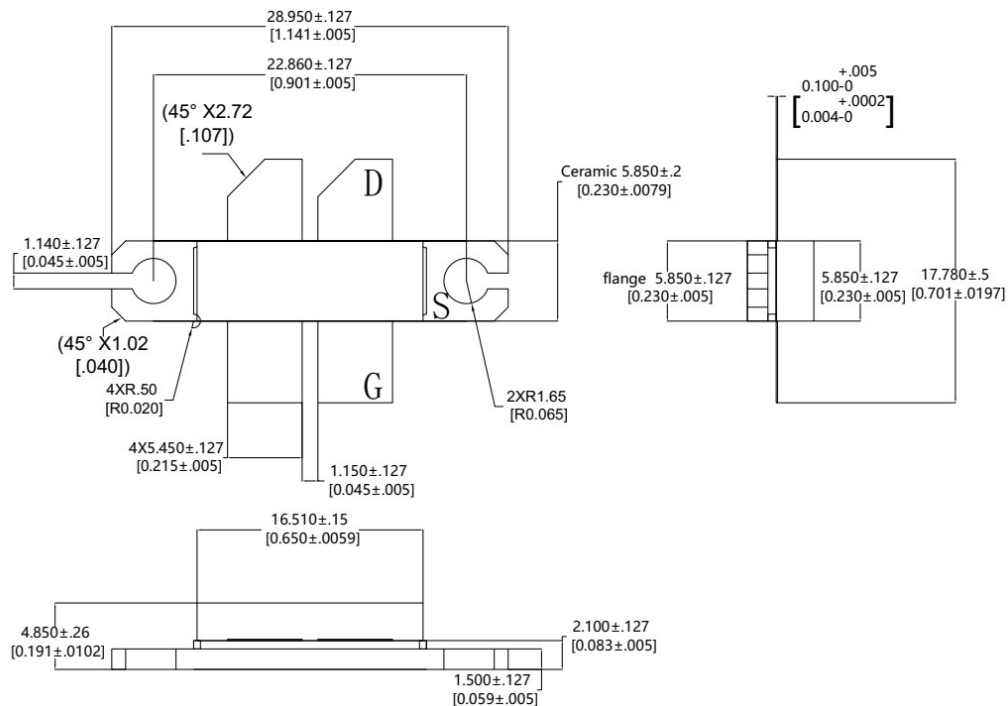
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NU6006H	Freq (MHz)	VDD (V)	Idq (mA)	Zsource (ohms)	Zload (ohms)	Pout (dBm)	Gain (dB)	Eff (%)
MXP	2500	28	150	1.7-j*4.2	3.7-j*3.1	49.33	13.74	76.66
MXE	2500	28	150	1.7-j*4.2	3.0-j*0.7	48.01	14.75	82.18
Trade Off	2500	28	150	1.7-j*4.2	3.1-j*1.6	48.83	14.36	79.69

NU6006H	Freq (MHz)	VDD (V)	Idq (mA)	Zsource (ohms)	Zload (ohms)	Pout (dBm)	Gain (dB)	Eff (%)
MXP	3000	28	150	1.9-j*6.3	3.2-j*5.3	49.22	12.30	75.56
MXE	3000	28	150	1.9-j*6.3	2.4-j*3.7	48.18	12.87	80.05
Trade Off	3000	28	150	1.9-j*6.3	2.7-j*4.2	48.72	12.78	79.14

## Package Outline

Flanged ceramic package; 2 mounting holes; 4 leads



OUTLINE VERSION	REFERENCE			EUROPEAN PROJECTION	ISSUE DATE
	IEC	JEDEC	JEITA		
PKG-LB/LBB					05/21/2021

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## Revision history

Table 4. Document revision history

Date	Revision	Datasheet Status
2018/10/26	V1.0	Preliminary datasheet creation
2018/11/13	V1.1	Modify Gp and Psat,and add loadpull data
2022/9/19	V1.2	Modify the LBB Pkg drawing

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